

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Sung Chul Kang, et al.)
Serial No.: 10/750,845) Group Art Unit: 1752
Filed: January 5, 2004)
For: PHOTORESIST COMPOSITION FOR) Examiner: Chu, John S. Y.
MULTI-MICRO NOZZLE HEAD COATER)

AMENDMENT AND RESPONSE

*8/15
center
JG 12/2007*
VIA EFS
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This Amendment and Response is in response to the Final Office Action dated September 28, 2007.

Please amend the application as follows: